

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Dureseti CHIDAMBARRAO, et al. Group Art Unit: 2814  
Appln. No. : 10/605,108 Examiner: PHAM, Long  
Filed : September 9, 2003 Confirmation No. 2107  
For : METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI  
ON SI/GE SUBSTRATE

NOTICE OF APPEAL

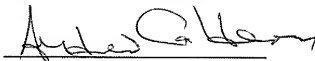
Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Window, Mail Stop AF  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314  
Sir:

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the Final Official Action of June 8, 2006 finally rejecting claims 16-18, 22-28 and 30-39. The following items are enclosed herewith:

- Payment in the amount of \$ 500.00 for the payment of the appeal fee as set forth in 37 C.F.R. 41.20(b)(1).
- A Request for Pre-Appeal Brief Review.

Please charge any additional fees necessary for consideration of the papers filed herein and refund excess payments to Deposit Account No. 09-0458.

Respectfully submitted,  
Dureseti CHIDAMBARRAO, et al.



Andrew M. Calderon  
Registration No. 38,093

August 23, 2006  
Greenblum & Bernstein, P.L.C.  
1950 Roland Clarke Place  
Reston, Virginia 20191  
Telephone: 703-716-1191  
Facsimile: 703-716-1180